

#### UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

Jennifer Stone-Sundberg, et al.

Title:

OPTICAL SPINEL ARTICLES AND METHODS FOR FORMING SAME

Application No.: 10/802,160

Filed:

March 17, 2004

Examiner:

Stephen J. Stein

Group Art Unit: 1775

Atty. Docket No.: 1035-BI4309

MS AMENDMENT **COMMISSIONER FOR PATENTS** PO Box 1450 Alexandria, VA 22313-1450

#### INFORMATION DISCLOSURE STATEMENT TRANSMITTAL

Dear Sir:

Pursuant to 37 C.F.R. § 1.56, § 1.97 and § 1.98, the undersigned brings the patents, publications, applications or other information identified in the attached:

Form(s) PTO/SB/08A and/or PTO/SB/08B or PTO/1449

Other: n/a

to the Examiner's attention in the above-identified application. Citation of such information shall not be construed as:

- an admission that the information necessarily is, or corresponds to, prior art with 1. respect to the instant invention;
- a representation that a search has been made, other than as described below; or 2.
- 3. an admission that the information cited herein is, or is considered to be, material to patentability as defined in § 1.56(b).

For each item of information listed that is not in the English language, the undersigned has provided a concise explanation of the relevance, such as through (i) an English language abstract, (ii) an English language equivalent application, (iii) reference to discussion in the application, or (iv) if cited in a search report or other action by a foreign patent office in a counterpart foreign application, an English language version of the search report or action that indicates the degree of relevance found by the foreign office.

### CERTIFICATE OF TRANSMISSION/MAILING I hereby certify that this correspondence is being facsimile transmitted to the USPTO or deposited with the United States Postal Service with sufficient postage as either First Class Mail or Expres Mail, in an envelope addressed to the Commissioner for Patents on 🙋 11-3-Elise K. Dougherty Typed or Printed Name

#### STATEMENT UNDER 37 C.F.R. § 1.704(d)

May 2	If the a 29, 2000	above-identified application is an original application filed on or after:
		each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart application and this communication was not received by any individual designated in § 1.56(c) more than thirty days prior to the filing of this Information Disclosure Statement.
		FEES DUE
	This I	nformation Disclosure Statement is being filed:
		within three months of the filing date of a national application or within three months of entry of the national stage as set forth in § 1.491 in an international application. Therefore, no fee is required.
		before the mailing date of a first Office action on the merits or before the mailing date of a first Office action after the filing of a request for continued examination under § 1.114. Therefore, no fee is believed required.
		during the period specified in § 1.97(c). Each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart application not more than three months prior to the filing of this Information Disclosure Statement.
		during the period specified in § 1.97(c). Accordingly, the fee set forth in § 1.17(p) is required and provided as shown on the attached Fee Transmittal.
		during the period specified in § 1.97(d). Accordingly, the fee set forth in § 1.17(p) is required and provided as shown on the attached Fee Transmittal. Additionally, each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart application not more than three months prior to the filing of this Information Disclosure Statement.

Should any PTO fees be necessary for entry of this Information Disclosure Statement, the undersigned hereby authorizes the Commissioner to charge Deposit Account <u>50-2469</u>.

11/2/05

Respectfully submitted,

Jeffrey S. Abel, Reg. No. 36,079

Attorney for Applicant(s)

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Austin, Texas 78746

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### LIST OF RELATED APPLICATIONS

Application No.	Filing Date	Applicant(s)	Docket No.
	•		
11/065,397	02/24/05	Tanikella, et al.	1075-BI4345

PTO/SB/08A (07-05)

Approved for use through 07/31/2006. OMB 0651-0031

U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE
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### INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

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Complete if Known				
Application Number	10/802,160			
Filing Date	03/17/2004			
First Named Inventor	Jennifer Stone-Sundberg			
Art Unit	1775			
Examiner Name	Stephen J. Stein			
Attorney Docket Number	1075-BI4309			

			U. S. PATEN	DOCUMENTS	
Examiner Initials*	Cite No.1	Document Number  Number-Kind Code <sup>2 (If known)</sup>	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevan Figures Appear
	A1	US- 3,753,775	08/21/1973	Robinson et al.	
	B1	<sup>US-</sup> 3,964,942	06/22/1976	Berkenblit et al.	
	C1	us- 4,649,070	03/10/1987	Kondo et al.	
	DI	<sup>US-</sup> 4,657,754	04/14/1987	Bauer et al.	
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	lT	CN 1291795	04/18/2001	Guanglei Sci & Tech Co. Ltd.	English Abstract Only	
	U1	CN 1379484	11/13/2002	Univ Qinghua	English Abstract Only	
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	W1	CN 1476046	02/18/2004	Shanghai Prec. Opt. Instr	English Abstract Only	
	X1	CN 1476047	02/18/2004	Shanghai Prec. Opt. Instr	English Abstract Only	
	Yl	EP 997445	05/03/2000	Corning Inc.	English Abstract Only	

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Complete if Known			
Application Number	10/802,160		
Filing Date	03/17/2004	-	
First Named Inventor	Jennifer Stone-Sundberg		
Art Unit	1775	-	
Examiner Name	Stephen J. Stein		
Attorney Docket Number	1075-BI4309		

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Examiner Initials*	Cite No.1	Document Number  Number-Kind Code <sup>2 (# known)</sup>	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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	B2	US- 2004/0063236 A1	04/01/2004	Kwak et al.	
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	D2	US-			
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	S2	US-			

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Examiner Initials*	Cite No.1	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages	
		Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	MM-DD-YYYY		Or Relevant Figures Appear	T <sup>6</sup>
	T2	EP 1298709	04/02/2003	NGK Insulators Ltd.	English Abstract Only	
	U2	EP 1394867	03/03/2004	Samsung Elect. Co. Ltd.	English Abstract Only	
	V2	JP 53-043481	04/19/1978	Matsushita Elec Ind. Co. Ltd.	English Abstract Only	
	W2	JP 79-026873	09/06/1979	Nippon Elect. Co.	English Abstract Only	
	X2	JP 58-090736	05/30/1983	Tokyo Shibaura Elect. Co	English Abstract Only	
	Y2	JP 61-142759	06/30/1986	NGK Spark Plug Co. Ltd.	English Abstract Only	

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Signature	Considered	

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Coi	mplete if Known	
Application Number	10/802,160	
Filing Date	03/17/2004	
First Named Inventor	Jennifer Stone-Sundberg	
Art Unit	1775	
Examiner Name	Stephen J. Stein	
Attorney Docket Number	1075-BI4309	

	U. S. PATENT DOCUMENTS						
Examiner Initials*	Cite No. <sup>1</sup>	Document Number  Number-Kind Code <sup>2 (f known)</sup>	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
	A3	US-					
	В3	US-					
	C3	US-					
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Examiner Cite Initials* No.1		Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages		
		Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	MM-DD-YYYY		Or Relevant Figures Appear	T <sup>6</sup>	
	T3	JP 62-123059	06/04/1987	Narumi Seito KK	English Abstract Only		
	U3	JP 7-235692	09/05/1995	Sony Corp.	English Abstract Only		
	V3	JP 8-040797	02/13/1996	Kyocera Corp.	English Abstract Only		
	W3	JP 8-083802	03/26/1996	Shingijutsu Kigyodan	English Abstract Only		
	X3	JP 8-095233	04/12/1996	Tono Seiki YG	English Abstract Only		
	Y3	JP 9-129651	05/16/1997	Hewlett-Packard Co.	English Abstract Only		

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Signature		Considered	

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### INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Coi	Complete if Known				
Application Number	10/802,160				
Filing Date	03/17/2004				
First Named Inventor	Jennifer Stone-Sundberg				
Art Unit	1775				
Examiner Name	Stephen J. Stein				
Attorney Docket Number	1075-BI4309				

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Examiner Initials*	Cite No.1	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevan Figures Appear
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	S4	US-			

FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages		
		Country Code <sup>3</sup> -Number <sup>4</sup> -Kind Code <sup>5</sup> ( <i>if known</i> )	MM-DD-YYYY		Or Relevant Figures Appear	T <sup>6</sup>	
	T4	JP 9-129928	05/16/1997	Toshiba KK	English Abstract Only		
	U4	JP 11-195813	07/21/1999	Toshiba Denshi Eng. KK	English Abstract Only		
	V4	JP 11-235659	08/31/1999	Ricoh KK	English Abstract Only		
	W4	JP 11-274559	10/08/1999	Sanyo Elect. Co. Ltd.	English Abstract Only		
	X4	JP 2000-228367	08/15/2000	Samsung Elect. Co. Ltd.	English Abstract Only		
	Y4	JP 2000-331940	11/30/2000	Sony Corp.	English Abstract Only		

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Stephen J. Stein

1075-BI4309

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	First Named Inventor	Jennifer Stone-Sundberg		
STATEMENT BY APPLICANT	Art Unit	1775		
(Use as many sheets as necessary)	Evaminer Name	Stephen I Stein		

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**S5** 

**Examiner Name** 

Attorney Docket Number

Sheet |5 **U. S. PATENT DOCUMENTS** Cite No.1 Examiner **Document Number** Publication Date Name of Patentee or Pages, Columns, Lines, Where Initials\* MM-DD-YYYY Applicant of Cited Document Relevant Passages or Relevant Number-Kind Code<sup>2 (if known)</sup> Figures Appear UŞ-A5 US-**B5** US-C5 US-**D**5 US-E5 US-F5 US-G5 US-H5 US-15 US-J5 US-K5 US-L5 US-M5 US-N5 US-**O5** US-P5 US-Q5 US-R5

FOREIGN PATENT DOCUMENTS							
Cite No.1	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages			
	Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	MM-DD-YYYY		Or Relevant Figures Appear	T <sup>6</sup>		
T5	JP 2001-010898	01/16/2001	NEC Corp.	English Abstract Only			
U5	JP 2001-198808	07/24/2001	Morioka Seiko Kogyo KK	English Abstract Only			
V5	JP 2001-220295	08/14/2001	Namiki Seimitsu Hoseki KK	English Abstract Only			
 W5	JP 2001-253800	09/18/2001	Namiki Seimitsu Hoseki KK	English Abstract Only			
 X5	JP 2002-012856	01/15/2002	Neos KK	English Abstract Only			
Y5	JP 2002-050577	02/15/2002	Namiki Seimitsu Hoseki KK	English Abstract Only			

Examiner	 Date	
Signature	Considere	d

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110	FORMATION DI	ISCI OSLIDE	Filing Date	03/17/2004	
			First Named Inventor	Jennifer Stone-Sundberg	
S	TATEMENT BY		Art Unit	1775	
	(Use as many sheets as	s necessary)	Examiner Name	Stephen J. Stein	
Sheet	6 of	13	Attorney Docket Number	1075-BI4309	

			U. S. PATENT D	OCUMENTS	
Examiner Initials*	Cite No.1	Document Number  Number-Kind Code <sup>2</sup> (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
	A6	US-			3
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	N6	US-			
	O6	US-			
	P6	US-			
	Q6	US-			
	R6	US-			
	S6	US-			

		FORE	IGN PATENT DOCI	UMENTS		
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		Country Code <sup>3</sup> -Number <sup>4</sup> -Kind Code <sup>5</sup> (if known)	MM-DD-YYYY	47	Or Relevant Figures Appear	1
	T6	JP 2002-158377	05/31/2002	Matsushita Denki Sangyo KK	English Abstract Only	
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1075-BI4309

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of 13

Attorney Docket Number

			U. S. PATENT D	OCUMENTS	
Examiner Initials*	Cite No.1	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant
	<b>-</b> -	Number-Kind Code <sup>2 (# known)</sup> US-			Figures Appear
	A7				
	B7	US-			
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FOREIGN PATENT DOCUMENTS								
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		Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	MM-DD-YYYY		Or Relevant Figures Appear			
	T7	JP 2003-165042	06/10/2003	Okamoto Kosaku Kikai Scisakusho KK	English Abstract Only			
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	V7	JP 2003-320521	11/11/2003	Tokyo Tungsten KK	English Abstract Only			
	W7	JP 2003-334754	11/25/2003	Nippon Microcoating KK	English Abstract Only			
	X7	JP 2003-338638	11/28/2003	Nichia Kagaku Kogyo KK	English Abstract Only			
- "	Y7	JP 2004-006867	01/08/2004	Matsushita Denki Sagyo KK	English Abstract Only			

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# INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Complete if Known				
Application Number	10/802,160			
Filing Date	03/17/2004			
First Named Inventor	Jennifer Stone-Sundberg			
Art Unit	1775			
Examiner Name	Stephen J. Stein			
Attorney Docket Number	1075-BI4309			

			U. S. PATENT D	OCUMENTS	
Examiner Initials*	Cite No.1	Document Number  Number-Kind Code <sup>2 (# known)</sup>	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
	A8	US-			
	B8	US-			
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	D8	US-		-	
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	F8	US-			
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	S8	US-			

		FOREIGN	PATENT DOCU	IMENTS		
Examiner Initials*	Cite No.1	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages	
		Country Code <sup>3</sup> -Number <sup>4</sup> -Kind Code <sup>5</sup> (if known)	MM-DD-YYYY		Or Relevant Figures Appear	T <sup>6</sup>
	T8	JP 2004-014691	01/15/2004	Mitsubishi Gas Chem Co Inc.	English Abstract Only	
	U8	JP 2004-140394	05/13/2004	Nissan Chem Ind. Ltd.	English Abstract Only	
	V8	KR 2002-043128	06/08/2002	Ulsan College	English Abstract Only	
	W8	SU 1781271	12/15/1992	Krasy Poly (Kypo)	English Abstract Only	
	X8	TW 550836	09/01/2003	Ind. Tech. Res. Inst.	English Abstract Only	
	Y8	WO 2000/68332	11/16/2000	MPM Ltd.	English Abstract Only	

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Attorney Docket Number	1075-B14309	7			

			U. S. PATENT		
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	T9	WO 2002/92674	11/21/2002	US Sec of Navy	English Abstract Only	
	U9	WO 2004/33769	04/22/2004	Unisearch Ltd.	English Abstract Only	
	V9				English Abstract Only	
	W9				English Abstract Only	
	X9				English Abstract Only	
	Y9				English Abstract Only	

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				Application Number	10/802,160	
INFO	DRMATION	DIS	CLOSURE	Filing Date	03/17/2004	
STA	TEMENT B	SY A	PPLICANT	First Named Inventor	Jennifer Stone-Sundberg	
	(Use as many she	ate se ni	eressan/l	Art Unit	1775	
	tose as many sne	cis as m	ecessary)	Examiner Name	Stephen J. Stein ,	
Sheet	10	of	13	Attorney Docket Number	1075-BI4309	

	r	NON PATENT LITERATURE DOCUMENTS	,
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
	A10	Aeschlimann, R. et al., "The Chemical Polishing of Magnesium Aluminate Spinel in Pyrophosphoric Acid", MAT. RES. BULL., Vol. 5, pgs 167-172, 1970.	
	B10	Dwikusuma, F., "Study on Sapphire Surface Preparation for III-Nitride Heteroepitaxial Growth by Chemical Treatments", JOURNAL FOR ELECTROCHEMICAL SOC., Nov. 2002, 30 pgs.	
	C10	Kim, S. et al., "Stress Relaxation in Thick-Film GaN Grown by Hydride Vapor Phase Epitaxy on Sapphire and Spinel Substrates as Studied by Photoluminescence and Raman Spectroscopy", J. OF THE KR PHYS SOC., Vol. 34, No. 2, Feb. 1999, pgs 163-167.	
	D10	Kurobe, Toshiji, et al., "Magnetic Field-Assisted Lapping", BULL. JAPAN SOC. OF PREC. ENGG., Vol. 20, No. 1, March 1986, pgs 49-51.	
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	G10	Richter, F., et al., "Herstellung und Aurichtung Von MgAl-Spinell-Substraten für die Halbleiterepitaxie", KRISTALL UND TECHNIK, Vol. 10, No. 3, 1975, pgs 33-348.	
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	I10	Roy, D., et al., "Spinel, Where did it go?", SPIE Vol. 3134, pgs 307-316.	
	J10	Wang, C., et al., "Growth and Characterization of Spinel Single Crystal for Substrate Use in Integrated Electronics", J. APPLIED PHYSICS, Vol. 40, No. 9, August 1969, pgs 3433-3444.	

Examiner	Date	
Signature	 Considered	

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INFO	ORMATIO	N DIS	CLOSURE	Filing Date	03/17/2004	
STA	TEMENT	BY A	PPLICANT	First Named Inventor	Jennifer Stone-Sundberg	
	(Use as many s	haate as a	nences and	Art Unit	1775	
	(Ose as many s	neets as m	ecessary)	Examiner Name	Stephen J. Stein	-
Sheet	11	of	13	Attorney Docket Number	1075-BI4309	

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
	All	Yanina, S., et al., "Moving Steps and Crystal Defects on Spinel Surfaces", MAT. RES: SOC. SYMP., Vol. 620, 2000, pgs M9.4.1-M9.4.6.	
	B11	Byun, D., et al., "Reactive ion (N2+) Beam Pretreatment of Sapphire for GaN Growth", THIN SOLID FILMS, Vol. 326, 1998, pgs 151-153.	
	C11	Byun, D., et al., "New Pretreatment Method of Sapphire for GaN Deposition", PHYS. STAT. SOL., Vol. 176, 1999, pgs 643-648.	
	D11	Sung, Y., et al., "High Rate Etching of Sapphire Wafer Using Cl2BCl3Ar Inductively Coupled Plasmas", MAT. SCI. & ENG.: SOLD STATE MAT, Vol. B82, No. 1-3 2000, pgs 50-52. (ABSTRACT ONLY)	
	Ell	Wang, X., et al., "Chemical Polishing of Sapphire for Growth of GaN", CHINESE JOURNAL OF SEMICONDUCTORS, Vol. 18, No. 11, pgs 867-871, 1997. (ABSTRACT ONLY)	·
	F11	Lee, J., et al., "Scribing and Cutting a Blue LED Wafer Using a Q-Switched Nd:YAG Laser", APPLIED PHYSICS, Vol. 70, No. 5, pgs 561-564, 2000. (ABSTRACT ONLY)	
	G11	Kalinski, Z., "Preparation of Sapphire Substrates for Gas Phase GaN Epitaxial Processes", KRISTAL UND TECHNIK, Vol. 12, No. 10, pgs 1105-1110, 1977. (ABSTRACT ONLY)	
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	I11	Kalinski, Z., et al., "Structural Etching of Al2O3 Substrate Plates Applied in Gaseous Epitaxy of GaN Layers", ELEKTRONIKA, Vol. 18, No. 3, 1977, pgs 117-119. (ABSTRACT ONLY)	
	J11	Lakew, B., et al., "High Tc Superconducting Bolometer on Chemically Etched 7 Micrometer Thick Sapphire", NASA, 1997, 21 pgs. (ABSTRACT ONLY)	

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	(Ose as many sne	ets as ne	ressary)	Examiner Name	Stephen J. Stein	
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	A12	Jeong, C., et al., "Dry Etching of Sapphuire Substrate for Device Separation in Chlorine-Based Inductively Coupled Plasmas", MAT. SCI. & ENG.: SOLID STATE MATERIALS, Vol. 93, No. 1-3, pgs 60-63, 2002. (ABSTRACT ONLY)	
	B12	Gu, E., et al., "Micromachining and Dicing of Sapphire, Gallium Nitride and Micro LED Devices with UV Copper Vapour Laser", THIN SOLID FILMS, Vol. 453-454, pgs 462-466, 2000. (ABSTRACT ONLY)	
	C12	Park, H., et al., "A Novel Process for the Generation of Pristine Saphire Surfaces", THIN SOLID FILMS, Vol. 422, No. 1-2, pgs 135-140, 2000. (ABSTRACT ONLY)	
	D12	Fenner, D., et al., "Ion Beam Nanosmoothing of Sapphire and Silicon Carbide Surfaces", SPIE, Vol. 4468, pgs 17-24, 2001. (ABSTRACT ONLY)	
	E12	Blecha, Z., et al., "On Fabrication of Sapphire Substrates (1102) for Epitaxy of Monocrystalline Silicon", JEMNA MECHANIKA A OPTIKA, Vol., 28, No. 12, pgs 249-351, 1983. (ABSTRACT ONLY)	
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	G12	Ehman, M., et al., "Mechanical Preparation of Sapphire Single-Crystal Surfaces by Vibratory Techniques", METALLOGRAPHY, Vol. 9, No. 4, pgs 333-339, 1976. (ABSTRACT ONLY)	
	H12	Druminiski, M., et al., "Deposition of Epitaxial Films on Spinel and Sapphire. Influence of Substrate Preparation", SIEMENS FORSCHUNGS - UND ENTWICKLUNGSBERICHTE, Vol. 5, No. 3, pgs 139-145, 1976. (ABSTRACT ONLY)	
	I12	Cullen, G., "The Preparation and Properties of Chemically Vapor Deposited Silicon on Sapphire and Spinel", JOURNAL OF CRYSTAL GROWTH, Vol. 9, pgs 107-125, 1971. (ABSTRACT ONLY)	
	J12	Liu, L., et al., "Substrates for Gallium Nitride Epitaxy", MAT. SCI. & ENG. REPORTS, Vol. R37, No. 3, pgs 61-127, 2000. (ABSTRACT ONLY)	

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	(Ose as many si	ieets as n	ecessary)	Examiner Name	Stephen J. Stein	
Sheet	13	of	13	Attorney Docket Number	1075-BI4309	

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	A13	Khattak, C., et al., "Production of Sapphire Blanks and Substrates for Blue LEDs and LDs", MAT. RES. SOC. SYMP PROCEEDINGS, V. 743, pgs 219-224, 2002. (ABSTRACT ONLY)		
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	C13	Duffy, M., et al., "Semiconductor Measurement Technology: Method to Determine the Quality of Sapphire, (NOTE) Final Report", RCA Labs, 1980, 77 pgs. (ABSTRACT ONLY)		
	D13	Duffy, M., et al, "Method to Determine Qulity of Sapphire, (NOTE) Interim Rept.", RCA Labs, 1975, 88 pgs. (ABSTRACT ONLY)		
	E13	Horie, S., et al., "Precision Grinding of Semiconductor - Related Materials", (JOURNAL) NEW DIAMOND, Vol. 20, No. 2, pgs 8-13, 2004. (ABSTRACT ONLY)		
	F13	Edgar, J., et al., "Substrates for Gallium Nitride Epitaxy", MAT. SCI. & ENG., PART R, Vol. R37, No. 3, pgs 61-127, 2002. (ABSTRACT ONLY)		
	G13	Author Unkown, "Specifications for Polished Monocrystalline Sapphire Substrates" 1996, Affiliation (Issuing Organization) SEMI Semiconductor Equipment & Materials International, USA. (Bibliographic Entry Only).		
	H13	Search Report for Technical Articles (Including various Abstracts of certain Identified References)		
	I13			
	J13			

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